PHYSICS

Giant gate-tunable bandgap renormalization and excitonic effects in a 2D semiconductor

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Understanding the remarkable excitonic effects and controlling the exciton binding energies in two-dimensional (2D) semiconductors are crucial in unlocking their full potential for use in future photonic and optoelectronic devices. Here, we demonstrate large excitonic effects and gate-tunable exciton binding energies in single-layer rhenium diselenide (ReSe₂) on a back-gated graphene device. We used scanning tunneling spectroscopy and differential reflectance spectroscopy to measure the quasiparticle electronic and optical bandgap of single-layer ReSe₂, respectively, yielding a large exciton binding energy of 520 meV. Further, we achieved continuous tuning of the electronic bandgap and exciton binding energy of monolayer ReSe₂ by hundreds of milli–electron volts through electrostatic gating, attributed to tunable Coulomb interactions arising from the gate-controlled free carriers in graphene. Our findings open a new avenue for controlling the bandgap renormalization and exciton binding energies in 2D semiconductors for a wide range of technological applications.

INTRODUCTION

Atomically thin two-dimensional (2D) semiconductors usually exhibit large bandgap renormalization and extraordinary excitonic effects due to quantum confinement and reduced dielectric screening (1–4). As a result, light-matter interactions in these systems are primarily governed by the enhanced excitonic effects, which have been exploited to develop exciton-based devices operated at room temperature (RT) (5). Future progress in this area hinges on the ability to control the excitonic effects of 2D semiconductors by precisely tuning their exciton binding energies (E_b). This is crucial for realizing the full potential of 2D semiconductors in photonic and optoelectronic applications.

One unique aspect of 2D semiconductors is their unprecedented tunability in both their electronic and optical properties, due to high susceptibility to the doping and environmental screening (1, 6–12). It has been theoretically predicted and experimentally demonstrated that Coulomb interactions in 2D semiconductors can be engineered to tune their quasiparticle (QP) bandgap (E_g) and E_b using different methods such as chemical doping (6), electrostatically gating (7), and engineering environmental screening (1, 8, 9, 11, 12). Among all the methods reported, electrostatic gating offers additional advantages including continuous tunability and excellent compatibility for integration in modern device technologies. Recent studies involving the use of optical measurements demonstrated that gate-controlled excitonic effects can be achieved in monolayer transition metal dichalcogenides

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(TMDs) (7). However, an overlap of the band-edge absorption step with strong excitonic resonances generally makes it challenging to accurately determine $E_{\rm g}$ of 2D semiconductors from their optical absorption spectrum (13).

To probe $E_{\rm b}$ of 2D semiconductors directly, one can use scanning tunneling spectroscopy (STS) and optical spectroscopy (e.g., differential reflectance or photoluminescence spectroscopy) to measure E_{g} and optical bandgap (E_{opt}), respectively (1, 14). Here, we used this approach to demonstrate the gate-tunable E_{g} and excitonic effects in monolayer ReSe2 on a back-gated graphene field-effect transistor (FET) device, as sketched in Fig. 1A. We observed a large E_b of 520 meV for monolayer ReSe₂ at zero gate voltage ($V_g = 0$ V). Moreover, we show that E_b of monolayer ReSe₂ can be continuously tuned from 460 to 680 meV by electrostatic gating, which can be mainly attributed to screening from gate-controlled free carriers in graphene. This is distinct from the previous study of gate-tunable $E_{\rm b}$ in 2D semiconductors wherein the semiconductors' own free carriers play a major role (7). These 2D semiconductor/graphene heterostructures have been widely used in the fabrication of transistors (15-17), photo detectors (18), and energy-harvesting devices (19). The ability to precisely tune the bandgap and excitonic effects of 2D semiconductors on graphene provides a new route for the optimization of the interfacial charge transport or light-harvesting efficiency. Therefore, we expect that our findings would have a profound impact in the field of novel electronic and optoelectronic devices based on artificially engineered van der Waals heterostructures.

RESULTS

Topographic imaging of monolayer ReSe₂ on graphene

Unlike hexagonal TMDs, monolayer ReSe_2 adopts a distorted 1T structure with triclinic symmetry (Fig. 1B), wherein four Re atoms slip off from their regular octahedral sites due to the charge decoupling from their d^3 electrons. This results in the formation of a 1D chain-like structure consisting of interconnected diamond-shaped Re₄ units along the *a* direction as shown in Fig. 1B (20, 21). Because of this, monolayer ReSe₂ exhibits unique in-plane anisotropic electronic and



Fig. 1. A monolayer ReSe₂ on a back-gated G/h-BN device. (A) Schematic illustration of a back-gated ReSe₂/graphene/h-BN device. (B) Top view of the atomic structure of monolayer ReSe₂. The two lattice vectors (*a* and *b*) are outlined by red lines. The lattice constants are *a* = 6.6 Å and *b* = 6.7 Å. The angle between *a* and *b* is 118.9°. (C) A representative STM image of a monolayer ReSe₂ flake on graphene/h-BN. Inset shows the STM line profile along the step edge. (D) Atomically resolved STM image of monolayer ReSe₂. The STM image reveals the unique 1D chains consisting of diamond-shaped Re₄ units along *a* direction (highlighted by orange line). The cross (X) marks the position where the differential conductance (dl/dV) spectra were taken.

optical properties, making it particularly attractive for near-infrared polarization-sensitive optoelectronic applications (22).

To probe the carrier-dependent excitonic effects, we transferred a monolayer ReSe₂ flake onto a clean back-gated graphene FET device consisting of a chemical vapor deposition–grown graphene monolayer placed on a hexagonal boron nitride (h-BN) flake that rests on a SiO₂ layer above a doped Si wafer (Fig. 1A). In contrast to the SiO₂ substrate, the atomic flatness of the underlying h-BN markedly reduces the surface roughness and charge inhomogeneity in graphene (6, 23, 24). The use of graphene not only enables the direct scanning tunneling microscopy (STM) measurement of the gated single-layer ReSe₂ but also improves the electrical contact to monolayer ReSe₂ (25–27).

Figure 1C shows a representative STM image of a monolayer ReSe₂ flake placed on the monolayer graphene/h-BN substrate. The STM height profile across the step edge of the ReSe₂ flake reveals an apparent height of ~0.8 Å, suggesting monolayer thickness (fig. S1). Further, the atomically resolved STM image (Fig. 1D) reveals a diamond chain-like structure as expected for monolayer ReSe₂ with a distorted 1*T* atomic structure (*21*). The lattice constants of ReSe₂ along the *a* and *b* directions (as marked in Fig. 1, B and D) are determined to be 6.6 ± 0.1 Å and 6.7 ± 0.1 Å, respectively, which are in good agreement with the previous study (*20*). It is also expected that moiré patterns would arise when the graphene was overlaid with the monolayer ReSe₂ at different twist angles. Several representative moiré patterns have been successfully captured in our STM images of different spatial regions of

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different samples (Fig. 2, A to C). Distinct from most twisted 2D heterostructures such as graphene on h-BN (28), the moiré patterns of ReSe₂/graphene exhibit two different periods along two crystallographic orientations (as marked by L_1 and L_2 in Fig. 2, A to F). This is due to the stacking of monolayer ReSe₂ with triclinic lattice symmetry on graphene with a honeycomb lattice. The unique moiré patterns observed here can be well reproduced (Fig. 2, D to F) using the geometrical analysis of twist angle–dependent moiré patterns of ReSe₂/graphene heterostructures (refer to section S2 for more details).

Electronic structure of monolayer ReSe₂

We then probed the local electronic properties of ReSe₂ using STS. We note that differential conductance (dI/dV) spectra acquired in several moiré regions exhibit similar features (refer to section S3 for more details). Figure 3A shows a representative dI/dV spectrum acquired over monolayer ReSe_2 (marked by a cross in Fig. 1D) at $V_g = 0$ V together with the local density of states (LDOS) calculated by density functional theory (refer to section S5 for more details). A wide bandgap and several prominent resonant peaks located close to both the conduction band (CB) and valence band (VB) edges have been captured in the dI/dV spectrum taken on the clean surface region (solid blue line in Fig. 3A). These features can be well reproduced in the calculated LDOS of a free-standing monolayer ReSe₂ (dashed red line in Fig. 3A and refer to section S5 for more details). A close examination of the calculated band structure of monolayer ReSe2 allows us to identify that the origin of the prominent resonant peaks at the CB side (C_1) is attributed to the dispersionless electronic bands as indicated in fig. S5.

We identify the band edges of each dI/dV spectrum using the method previously reported (1). The VB maximum (VBM) and the CB minimum (CBM) are found to be located at -1.27 ± 0.01 eV and 0.72 ± 0.01 eV, respectively, which yields $E_{\rm g}$ of 1.99 ± 0.02 eV for monolayer ReSe₂. In addition, we observe the Fermi level ($E_{\rm F}$) to be closer to the CBM than the VBM, indicating a low n-doping of ReSe₂, which is presumably due to the presence of donor-like defects with shallow mid-gap states (fig. S4A).

Gate-tunable QP bandgap renormalization

One unique aspect of this study is that we can probe the QP band structures as a function of gate voltage. Figure 3C shows the gate-dependent dI/dV spectra taken at the same position over monolayer ReSe₂. We observed that a gate-dependent rigid shift of the CBM and C₁ toward E_F when V_g is changed from -63 to +45 V (Fig. 3, B and C). Unexpectedly, the VBM remains nearly constant at different gate voltages as shown in Fig. 3 (B and C). The distinct shift of the CBM and VBM with the increase in the applied gate voltage therefore indicates a monotonic reduction of E_g . The QP bandgap of monolayer ReSe₂ is determined to be 2.15 ± 0.01 eV at $V_g = -63$ V and 1.93 ± 0.02 eV at $V_g = 45$ V, respectively.

Probing the optical bandgap of monolayer ReSe₂

We performed the differential reflectance spectroscopic measurement of monolayer ReSe₂/graphene/h-BN at 5 K to probe its optical bandgap. Differential reflectance spectra of the sample after the background subtraction are shown in Fig. 3D (refer to fig. S6A for more details). At $V_g = 0$ V, E_{opt} of monolayer ReSe₂ is determined to be 1.47 ± 0.01 eV at 5 K based on the peak position of differential reflectance spectrum (Fig. 3D), consistent with previous results (22). To probe the electrostatic gating effect on E_{opt} , we monitored the evolution of the peak position of the hybrid ReSe₂/graphene device as a function of gate voltage.



Fig. 2. STM images of moiré pattern in monolayer ReSe₂/graphene. (A to C) Representative moiré patterns observed in the experiment. (D to F) Calculated moiré patterns obtained from the geometrical analysis. θ is the stacking angle between ReSe₂ and graphene.



Fig. 3. Gate-dependent *dl/dV* and differential reflectance spectra of a monolayer ReSe₂ on graphene. (A) *dl/dV* spectrum of monolayer ReSe₂ (blue line) at $V_g = 0$ V together with the calculated LDOS (dashed red line). (B) Energy position of VB maximum (VBM; red points) and CB minimum (CBM; dark blue points) as a function of the gate voltage. (C) Gate-dependent *dl/dV* spectra of the monolayer ReSe₂ on graphene/h-BN measured at 4.5 K. As-applied gate voltage is indicated above each STS curve. The VBM and CBM were indicated by light red and light blue points, respectively. (D) Gate-dependent differential reflectance spectra of the monolayer ReSe₂ on graphene/h-BN measured at 5 K. The corresponding gate voltage is indicated on the side of each differential reflectance spectrum. Note: The original differential reflectance spectra after background subtraction (circles); fitted curves using the Lorentzian function (solid lines). a.u., arbitrary units.

We found that E_{opt} remains nearly constant at all the gate voltages as opposed to the monotonic reduction of E_g (Fig. 3, C and D). It reflects that the renormalization of E_g is nearly fully offset by the change of E_b , in agreement with Koopmans' theorem adapted for semiconductors and previous experimental studies (9, 29, 30). To further verify this, we performed photoluminescence measurement of monolayer $ReSe_2/graphene/h-BN$ at different gate voltages at RT. The gate-dependent photoluminescence spectra acquired at RT also reveal a nearly constant E_{opt} of monolayer $ReSe_2$ (fig. S6B).

Gate-tunable exciton binding energy

The exciton binding energy is directly determined from the equation $(E_b = E_g - E_{opt})$. As shown in Fig. 4A, a large gate-tunable bandgap renormalization of ReSe₂ can be achieved in our hybrid device, whereby E_b can be precisely tuned over a wide energy range from 680 ± 20 meV to 460 ± 20 meV when V_g increases from -63 to +45 V. The pertinent question to be addressed in this work is the physical origins of the gate-tunable QP bandgap renormalization and exciton binding energy in monolayer ReSe₂. We are able to exclude the contribution from the out-of-plane field-induced polarization of CBM and VBM wave functions (namely, Stark effects). The vertical field induced polarization of electrons and holes in monolayer TMDs is negligible due to their extreme confinement in the in-plane direction (7). In addition, the screening by graphene substrate substantially reduces the vertical electric field effect for monolayer ReSe₂.

On the other hand, free carriers in both ReSe_2 and adjacent graphene can, in principle, contribute to the renormalization of $E_{\rm g}$ and tunable $E_{\rm b}$ in single-layer ReSe_2 . It has been predicted that $E_{\rm g}$ of a free-standing 2D semiconductor can be substantially reduced because of the presence of free carriers (31, 32). Further, the dominant contribution to the QP bandgap renormalization in these systems is predicted to arise from the Coulomb-hole self-energy and screened-exchange self-energy (31). However, a detailed analysis of the experimental data reveals that the renormalization of $E_{\rm g}$ and tunable $E_{\rm b}$ is not likely to arise from the presence of free carriers in ReSe_2 . First, the set of gate-dependent dI/dVspectra shows that $E_{\rm F}$ never crosses the band edge of ReSe_2 (Fig. 3C), suggesting the absence of free carriers residing in the band edge states. We also considered the potential free carriers contributed from point



Fig. 4. Gate-tunable bandgap renormalization and exciton binding energy of monolayer ReSe₂ **on graphene.** (**A**) A plot of QP bandgap E_g (black points), optical bandgap E_{opt} (red points), and exciton binding energy E_b (blue points) as a function of gate voltage. Note: The $E_{opt} = 1.47 \pm 0.01$ eV remains constant when the gate voltage increases from -40 to 40 V. Note: The same E_{opt} is used for the calculation of E_b at the gate voltage of -63, -60, -50, and +45 V. The solid blue line refers to the theoretically predicted E_b as a function of the gate voltage (refer to section S8 for more details). (**B**) Illustration of the screening of electron-hole interactions in monolayer ReSe₂ by the gate-controlled free carriers in graphene. (**C**) Schematic illustration of gate-tunable E_g and E_b of monolayer ReSe₂ at the gate voltage of -63 and +45 V, respectively.

defects with shallow mid-gap states in ReSe₂ (refer to section S4 for more details), although our gate-dependent dI/dV spectra of monolayer ReSe₂ are taken in the region free of defects. However, our STM imaging and spectroscopy measurements reveal that these defects with a low density of ~3.9 (± 1.5) × 10¹¹ cm⁻² are electronically isolated from each other (fig. S4). Therefore, the carriers localized around these defects are not likely to play a significant role in the renormalization of E_{g} .

These observations suggest that bandgap renormalization and tunable $E_{\rm b}$ of monolayer ReSe₂ are the result of the gate-induced free carriers in graphene. To further examine our hypothesis, we performed the gatedependent STS measurement of a new device consisting of monolayer graphene stacked on top of a monolayer ReSe2 on SiO2/Si substrate. By reversing the stacking order (graphene/ReSe₂), we are able to measure gate-dependent Dirac point (E_D) of graphene and E_g of monolayer ReSe₂ simultaneously (refer to section S7 for more details). The results also show a gate-tunable bandgap renormalization of monolayer ReSe₂ (fig. S7F). Moreover, it is observed that E_g of ReSe₂ reaches the maximum close to the charge neutrality point of graphene and reduces monotonically upon increase in either n-doping or p-doping of graphene (fig. S7F). Thus, a simultaneous measurement of both E_g of ReSe₂ and doping in graphene demonstrates that the observed gate-tunable bandgap renormalization and excitonic effects in monolayer ReSe₂ are attributed to the screening from the gate-controlled free carriers in the adjacent graphene.

We then used a quasi-classical model based on the Thomas-Fermi screening theory (refer to section S8 for more details) to calculate E_b of monolayer ReSe₂ on graphene/h-BN as a function of the carrier density in graphene (*n*). The screening model comprises two components: the Thomas-Fermi screening radius due to the free electrons in graphene and an effective dielectric constant ($\varepsilon_{eff} = 6.09$) that accounts for the combined dielectric permittivity of h-BN and ReSe₂ (see section S8 for derivation). Our theoretical results show that a moderate doping (*n* about 8 × 10¹² cm⁻²) in graphene substantially reduces the exciton binding energy by hundreds of milli–electron volts, resulting in a

monotonic decrease in $E_{\rm b}$ as the free-carrier concentration in graphene increases (fig. S8A).

To directly compare with experimental results, we need to convert the carrier density in graphene to the corresponding gate voltage (V_{α}) . The carrier density in the ReSe₂/graphene hybrid system depends linearly on the gate voltage: $n = \alpha (V_g - V_0)$. Here, α is estimated to be around 7.1×10^{10} cm⁻² V⁻¹ using a standard capacitor model (consisting of ~285-nm SiO₂ and ~15-nm h-BN as dielectric materials) (33, 34). Note that αV_0 is the initial doping of the system at $V_g = 0$ V. Since the density of defects with mid-gap states is extremely low (3.9 (\pm 1.5) × 10^{11} cm^{-2}) compared with the total gate-induced free-carrier density $(\Delta n = 7.7 \times 10^{12} \text{ cm}^{-2})$ and E_{F} is away from band edges of ReSe₂, this rationalizes that most of the gate-induced free carriers are injected into the underlying graphene. When V_0 is set as -64 V, we find the calculated E_b as a function of gate voltage agrees with the observed gate-dependent $E_{\rm b}$ (Fig. 4A). This suggests that the graphene underneath monolayer ReSe_2 is strongly n-doped at $V_g = 0$ V, in line with the charge transfer analysis discussed in section S9.

DISCUSSION

In summary, we have successfully tailored the QP bandgap and the exciton binding energy in a 2D semiconductor by controlling the doping in the underlying graphene using electrostatic gating. Our results show that screening from a graphene substrate has a profound impact on Coulomb interactions in adjacent 2D semiconductors and leads to broad tunability of the electronic bandgap and exciton binding energy. Our findings not only result in the unprecedented understanding of many-electron physics in hybrid 2D semiconductor/graphene systems but also pave the way toward controlling the excitonic effects and precisely tuning the exciton binding energies in 2D semiconductors for a wide range of technological applications.

MATERIALS AND METHODS

Sample preparation

We fabricated the graphene/h-BN sample based on the recipe reported previously (35). We then used the well-established dry transfer technique to place a monolayer ReSe_2 on top of graphene/h-BN sitting on SiO_2/Si substrate (36). The key steps for the sample treatment include the following: (i) The h-BN/SiO₂/Si substrate was annealed in the furnace at 500°C for 2 hours before the transfer of graphene. (ii) After the transfer of graphene, graphene/h-BN/SiO₂/Si sample was annealed in furnace with a flow of 100 sccm (standard cubic centimeters per minute) H₂ and 200 sccm Ar at 350°C for 5 hours. (iii) ReSe₂/graphene/h-BN was annealed at 300°C in the ultrahigh vacuum chamber for 12 hours.

STM and STS measurements

Our STM and STS measurements were conducted at 4.5 K in the Omicron LT-STM system with a base pressure lower than 10^{-10} mbar. The STM tip was calibrated spectroscopically against the surface state of Au(111) substrate. All the dI/dV spectra were measured through a standard lock-in technique with a modulated voltage of 5 to 10 mV and the frequency of 700 to 800 Hz.

Differential reflectance and photoluminescence measurements

The differential reflectance measurements and photoluminescence measurements were conducted at 5 K and at RT, respectively, using a

custom-built confocal spectrometer. For differential reflectance measurements, samples were illuminated by the white light from broadband source (hydrogen-halogen lamp) focused into the spot of ~2 µm. Reflectance spectra from monolayer ReSe₂ (R_{ReSe_2}) and substrate (R_{sub}) were collected in confocal geometry. Differential reflectance spectra (DR) are obtained by DR = ($R_{sub} - R_{ReSe_2}$)/ R_{sub} . For photoluminescence measurements, samples were excited with a 532-nm laser through the 100× objective lens (numerical aperture of 0.9) with a power below 0.5 mW.

SUPPLEMENTARY MATERIALS

Supplementary material for this article is available at http://advances.sciencemag.org/cgi/ content/full/5/7/eaaw2347/DC1

- Section S1. Atomic force microscopy measurement of monolayer ReSe₂
- Section S2. Moiré pattern of single-layer ReSe₂ on graphene
- Section S2.1. Moiré patterns for various twist angles
- Section S2.2. A comparison between experimental and theoretical moiré patterns
- Section S3. Gate-dependent dl/dV spectra of a different ReSe₂/graphene device
- Section S4. Probe the defects in monolayer ReSe₂
- Section S5. Band structure of monolayer ReSe₂
- Section S6. Differential reflectance spectrum and gate-dependent photoluminescence spectra of monolayer ReSe_2
- Section S7. Gate-dependent dl/dV spectra of graphene/monolayer ReSe₂
- Section S8. Calculation of $E_{\rm b}$ in monolayer ReSe₂ as a function of the carrier density in graphene substrate
- Section S9. Charge transfer at the interface of ReSe₂/graphene
- Fig. S1. Identify the thickness of monolayer ReSe₂.
- Fig. S2. Moiré lengths of ReSe_2 /graphene as a function of twist angle.
- Fig. S3. Gate-dependent dI/dV spectra of a different device.
- Fig. S4. STM images and STS measurements of defects in ReSe_2 .
- Fig. S5. Band structure of monolayer $ReSe_2$ calculated using the first-principle density functional theory calculations with the Perdew-Burke-Ernzerhof exchange-correlation functional using the QUANTUM ESPRESSO code.
- Fig. S6. Differential reflectance spectrum and gate-dependent photoluminescence spectra of monolayer ReSe₂ on graphene/h-BN.
- Fig. S7. Gate-dependent dl/dV spectra of graphene/monolayer ReSe₂.
- Fig. S8. Exciton binding energy (E_b) and Thomas-Fermi screening radius (r_s) as a function of electron concentration (n) in graphene.
- Fig. S9. Charge transfer at ReSe₂/graphene interface.
- Table S1. Geometrical properties of the moiré patterns of ReSe₂/graphene. References (37-46)

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